



Low mass hybrid technology



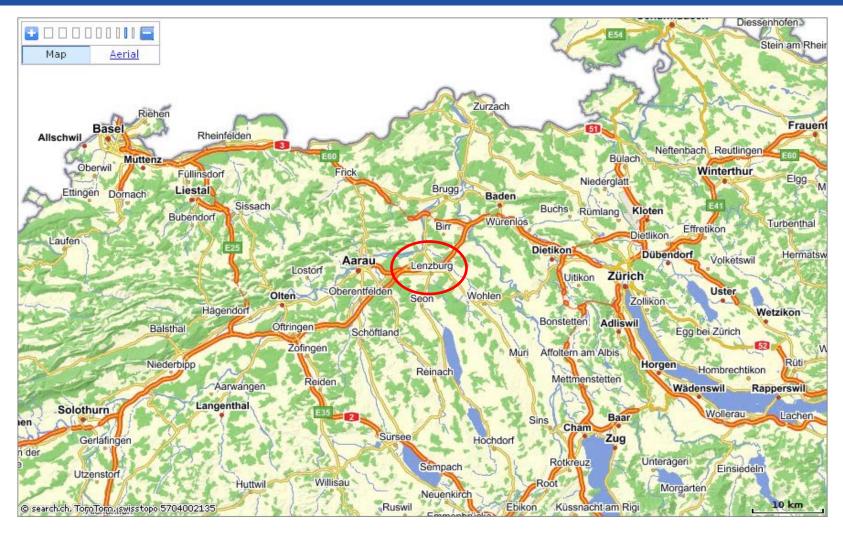


History

- HiCoFlex[®] serial production on 24" glass panels
- 2010 First prototypes on 24" glass panels
- 2008 Strategic decision for a 24" production line
- 1998 Thin film production (HiCoFlex[®]) on 6" glass panels
- 1992 Foundation of Hightec MC AG
- 1991 Merging of Thin Film Division Lenzburg and Oerlikon Contraves Thin Film Division Zurich
- 1989 Sell-off Thin Film Division Lenzburg to Oerlikon Contraves
- 1979 Thin film production on 4" ceramic panels by BBC (today ABB) Thin Film Division Lenzburg



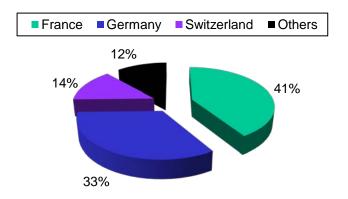
Location

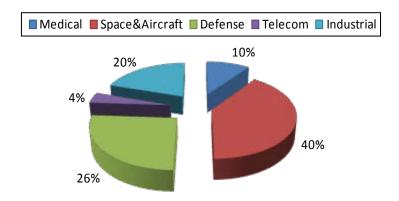


http://www.hightec.ch/



Facts





Sales by region

Sales: CHF 7.4 Mio

Sales by application





Typical Products

HiCoFlex®	MCM-D	Hybrids	Sensors	Structured Substrates	Resistor Networks
			ere MC	And a start of the	
 Highest density multilayer flex High density flex cables Integrated electronic inter- connections CSP 3D packaging 	 Multilayer up to 5 layers SMD Integrated high- precision thin film resistors 	 Integrated high- precision thin film resistors Mounting of controller dices MIL STD 883 	 Thin film sensors Optoelectronic devices Customised sensor housing Integrated passive components available 	 Microwave circuits Submounts for optoelectronic devices Pitch adapters Interposers 	 DIL, SIL, SMD Tolerance: 0.05% Lowest temperature drift harsh environment proved



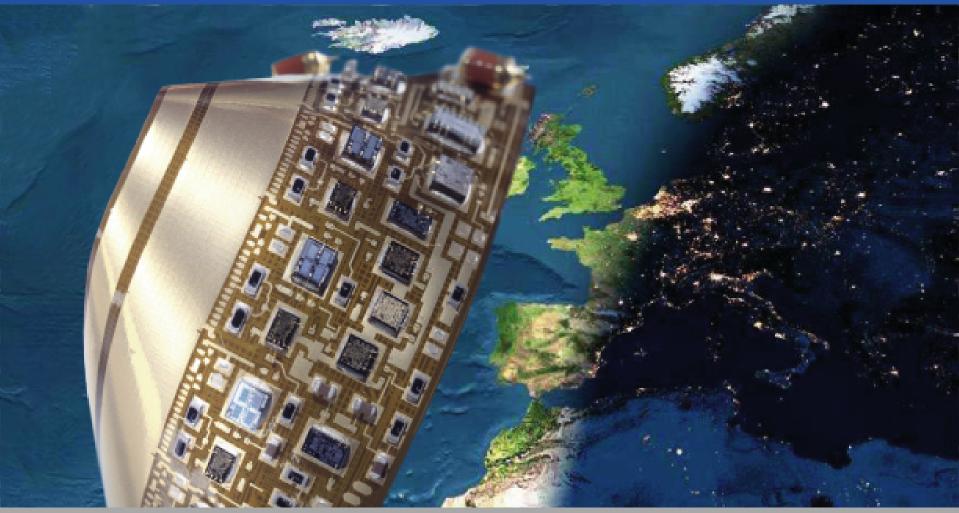
Our Identity

- All products are custom-made
- Full range of services from a single source
 - Developing, Micromachining and Assembling
 - Feasability Studies, Design, Prototyping, Manufacturing, Testing
- HiCoFlex[®]: High Connectivity Flex
 - Multilayer flex foils
 - Down to 20 µm layer flex foils thickness available
 - Up to 24" production panel size





HiCoFlex[®]



ISO 9001 certified



The HiCoFlex[®] Process: Carrier

Ceramics, glass or metal

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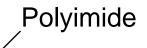


The HiCoFlex[®] Process: Separation Layer





The HiCoFlex[®] Process: 1st Polyimide Layer

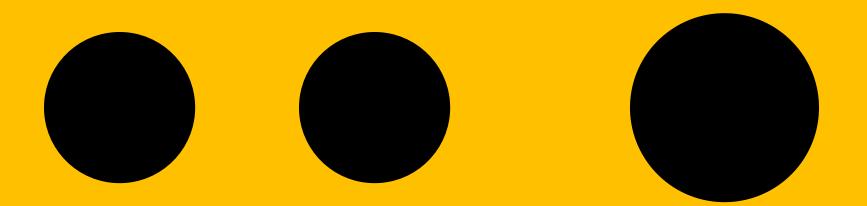


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The HiCoFlex[®] Process: 1st Metal after Structuring



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The HiCoFlex[®] Process: 2nd Polyimide Layer





The HiCoFlex[®] Process: Vias

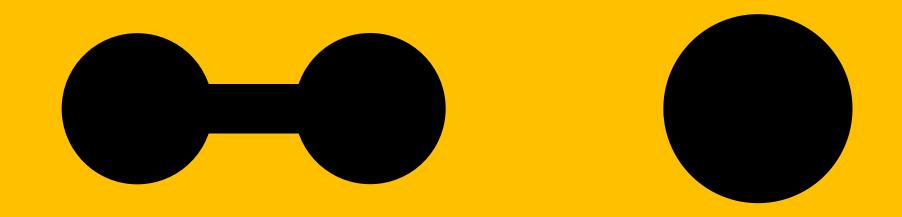


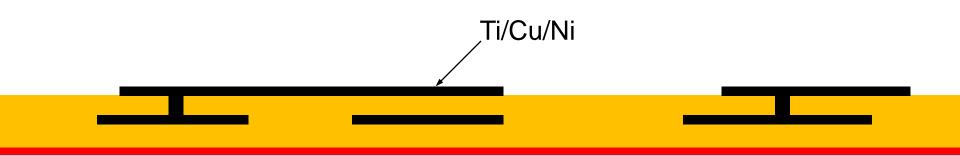
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The HiCoFlex[®] Process: 2nd Metal after Structuring

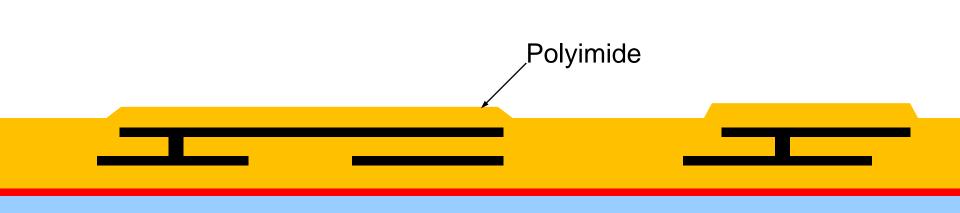






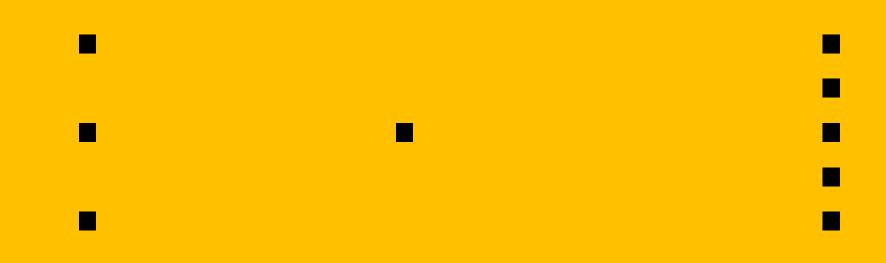
ISO 9001 certified

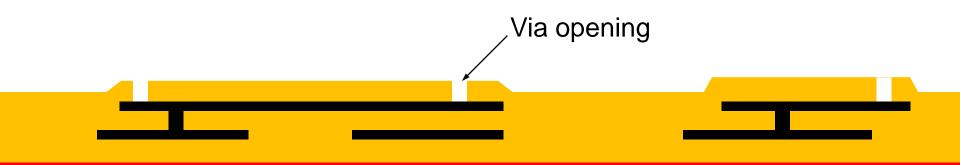
The HiCoFlex[®] Process: 3rd Polyimide Layer





The HiCoFlex[®] Process: Vias



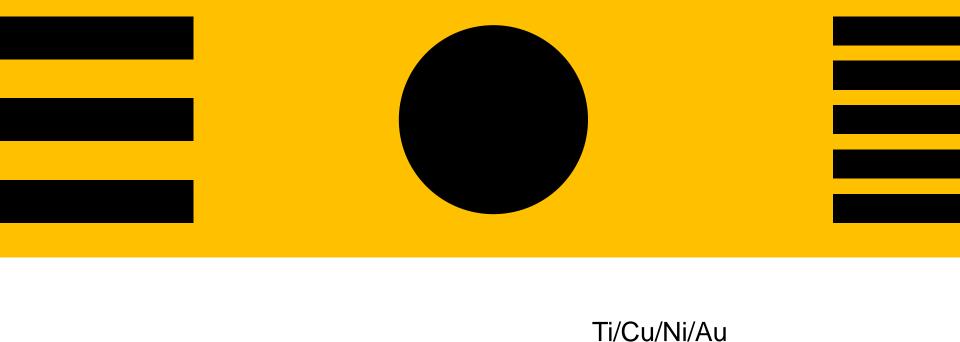


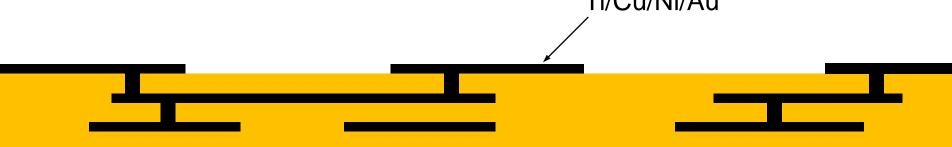
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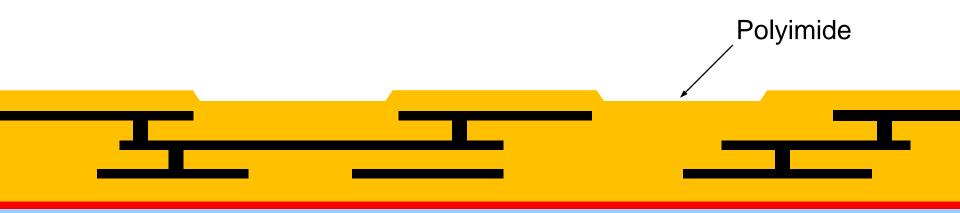
The HiCoFlex[®] Process: 3rd Metal after Structuring







The HiCoFlex[®] Process: 4th Polyimide Layer

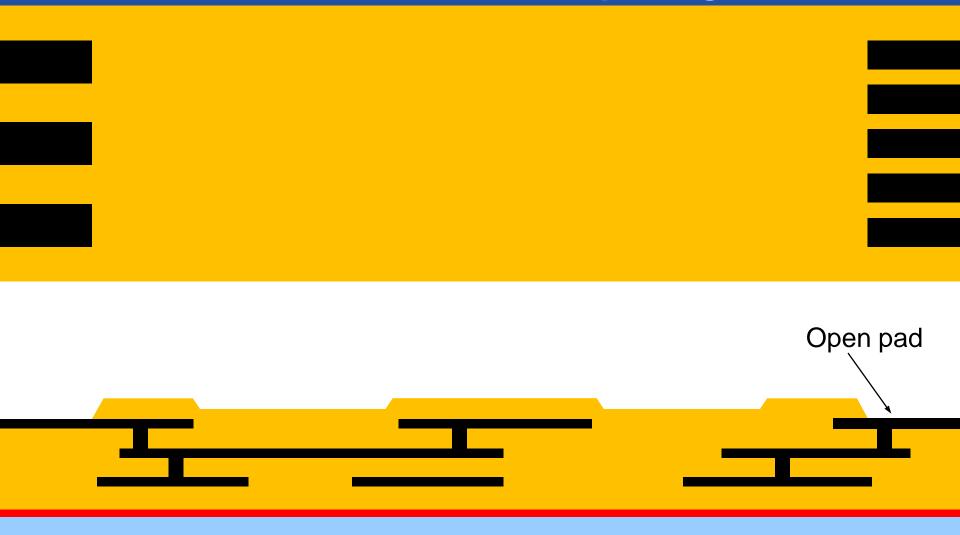


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The HiCoFlex[®] Process: Opening Pads

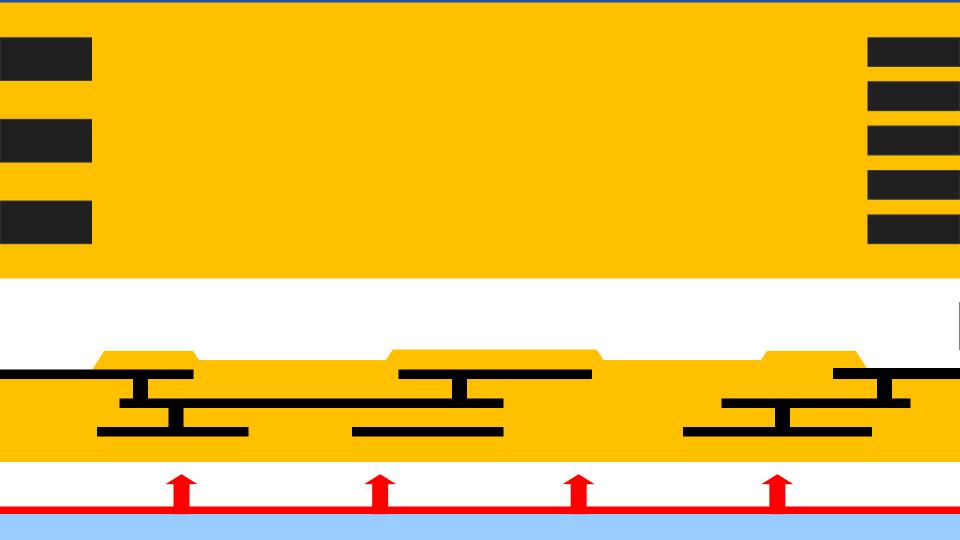


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The HiCoFlex[®] Process: Force-free Separation





HiCoFlex[®] Technology

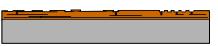


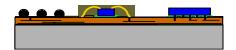
21.11.2011

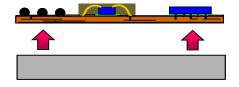
Fabrication of multilayer structure on rigid carrier substrate

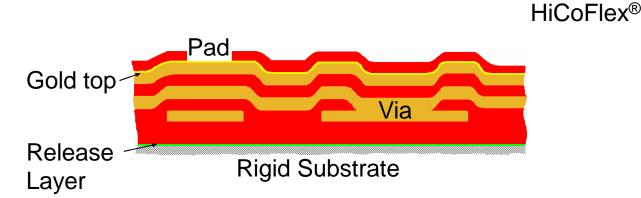
Assembling, Bonding Protection, Test

Separation of multilayer from rigid substrate









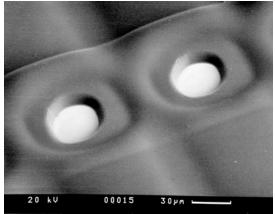


HiCoFlex® Technology

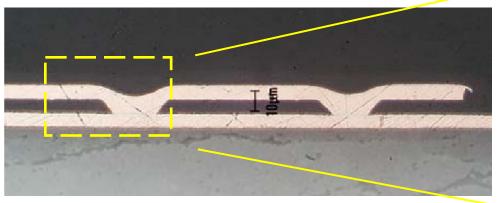


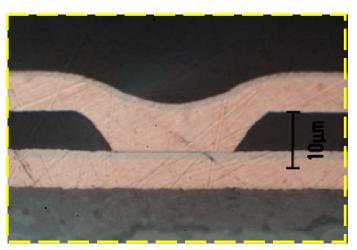
15 μm line/space conductors

Laser cut vias \varnothing 30 μ m



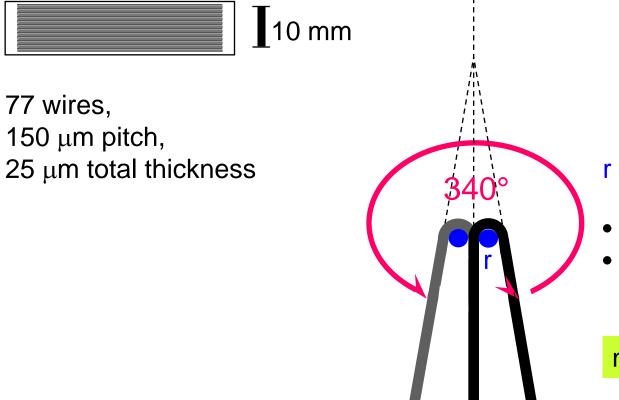
Electroplated vias







HiCoFlex[®] **Technology**



r = 1 mm

- no mechanical damage
- no change in electrical properties

number of cycles $> 10^7$



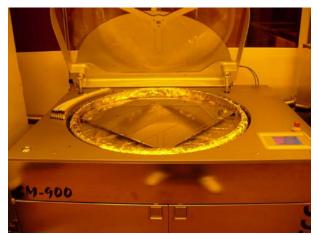
The HiCoFlex[®] line of Hightec MC AG

- Glass substrates 24" x 24"
- Higher volume at lower cost
- Larger flex formats
- Equipment:
 - LDI for 15 µm line and space
 - Sputter Tool (vertical)
 - Electroplating Cu, Ni, Au
 - UV Laser
 - AOI
 - Spray Clean, Develop, Etch and Strip
 - 3D Measurement Microscope, etc.
- Investment 8 Mio. CHF





24" Production Line



Spin Coating



Hotplates



LDI & Electro Plating



Resist Develop 3D Thickness Measurement

Prober

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HiCoFlex[®] Applications

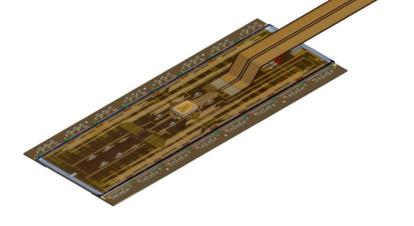


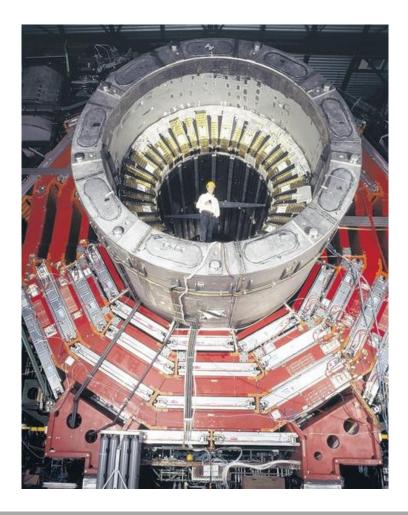


HDI / VHDI

3-layer HDI flex CMS experiment in the Large Hadron Collider (LHC) at CERN

Assembled barrel modul for 66560 pixels on 67mm x 26mm (courtesy of PSI, Villigen)







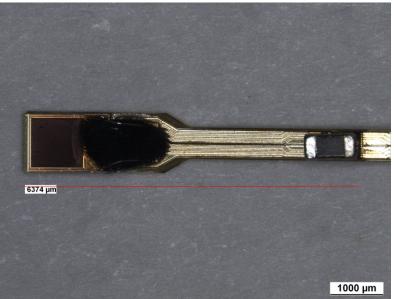
HiCoFlex Long Micro Cables

Medical application for catheder and endoscope connection

For example:

- Length typ. \geq 0.5m
- Width $\leq 1 2 \text{ mm}$
- Number of layers: from 2 to 3



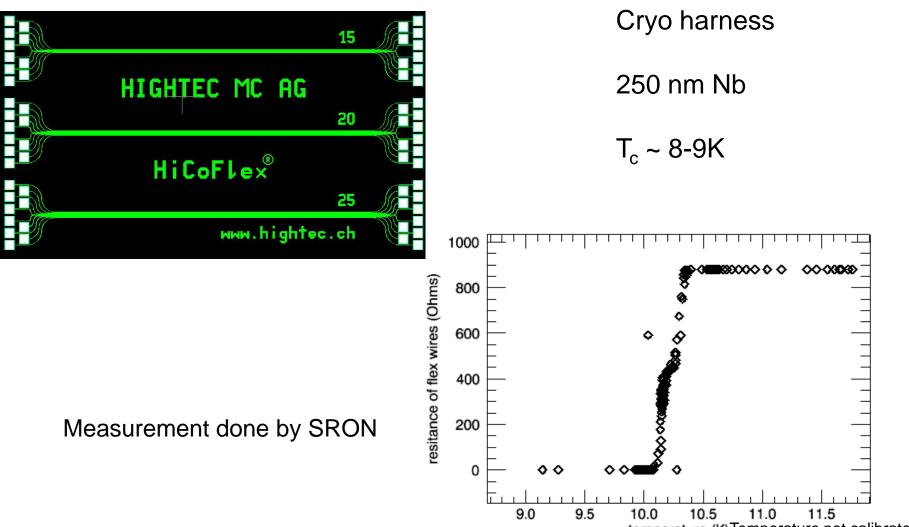


550mm

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Cables for Space Applications

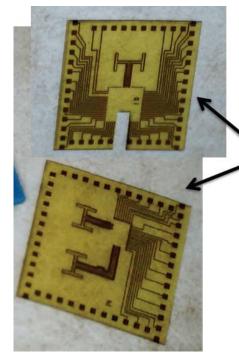


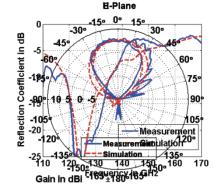
temperature (K)Temperature not calibrated



High-Frequency Application – 122GHz

www.success-project.eu





Antennas on HiCoFlex (14 µm Polyimide)

 \rightarrow Double Dipole Antenna

→ Uses package base as reflector <text><text>

- Performance including the flip chip interconnect:
- 17 GHz Bandwidth
- 11 dBi Gain
- No sidelobes
- Not affected by interconnect lines

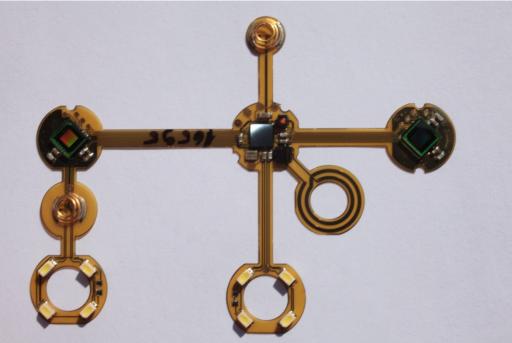


Medical Devices

Multiple folded flex board for Pill Cam Manufacturing of flex board, assembly of components, testing of function on a rigid substrate



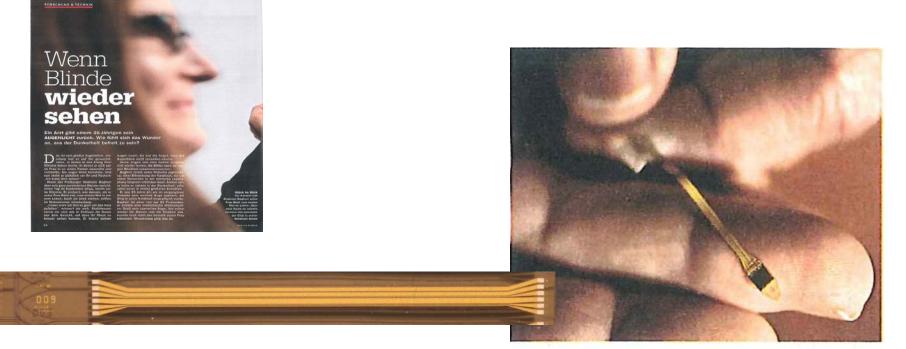






Medical Devices – Retina Implant

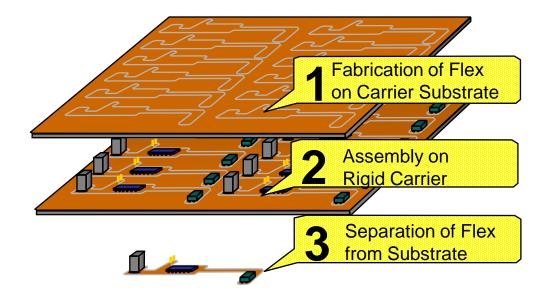
Article in Focus 6/2012

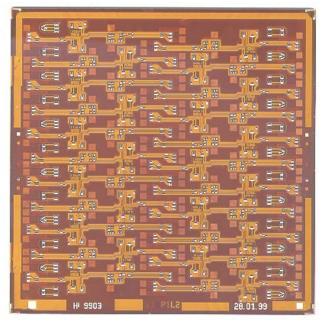


High-Tech-Auge Dieser Chip wird in die kranke Netzhaut implantiert. Bald soll er Tausenden Blinden helfen

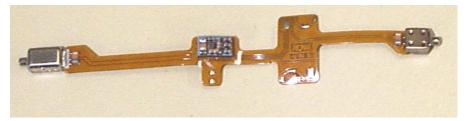


HiCoFlex® Assembly on 6" Panels





6" Substrate before Assembly

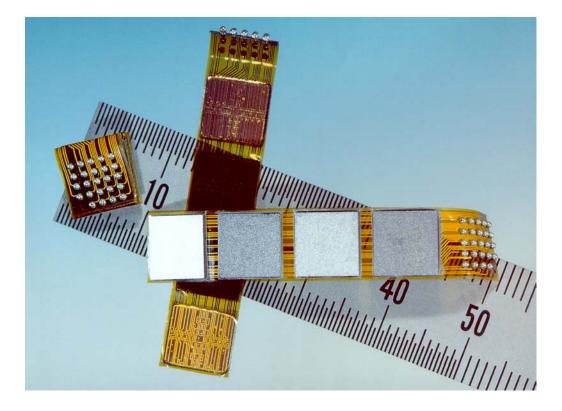


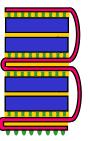
Final part assembled and separated

ISO 9001 certified



HiCoFlex® 3D-Packaging



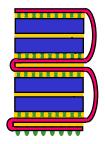


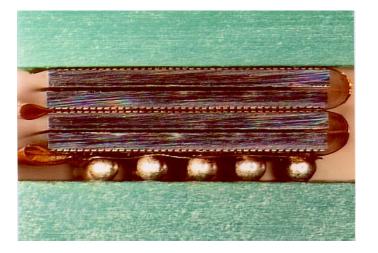
ISO 9001 certified



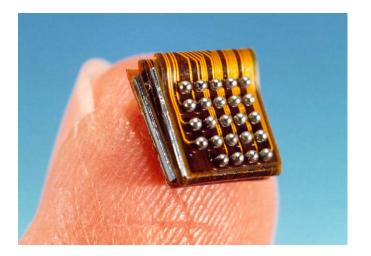
HiCoFlex[®] MCSP!

4 ICs, 7 x 7 mm, Flip-Chip on *HiCoFlex*[®] BGA Pitch 1.27 mm Flip-Chip PbSn-Solder Interconnections Pitch 180 μm



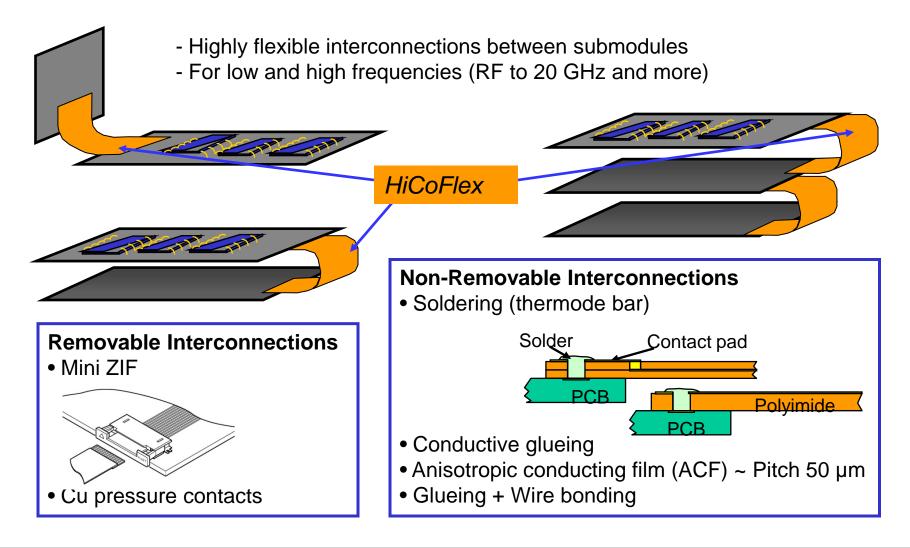


Side View





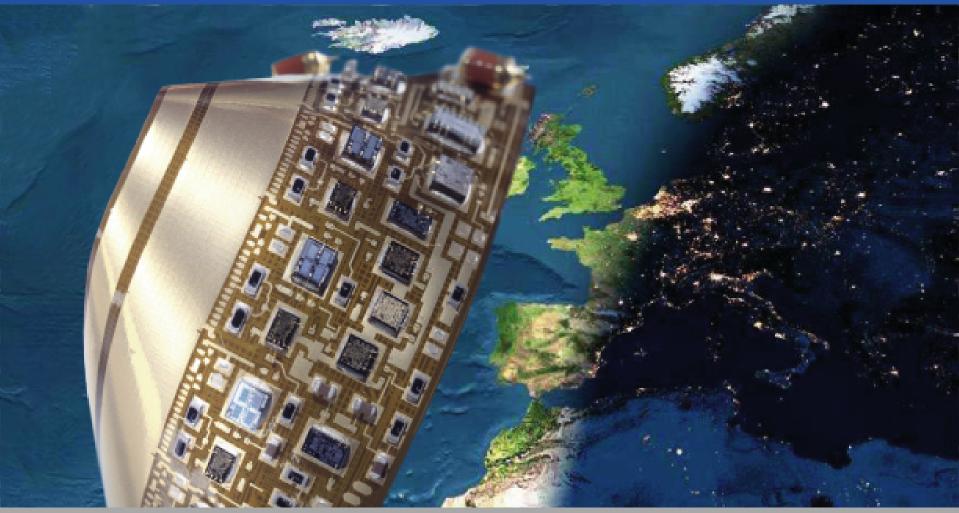
HiCoFlex® Cables and Interconnections





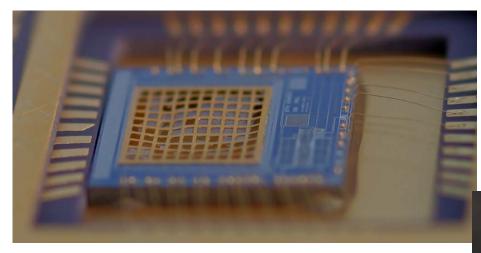


Customised Assembling



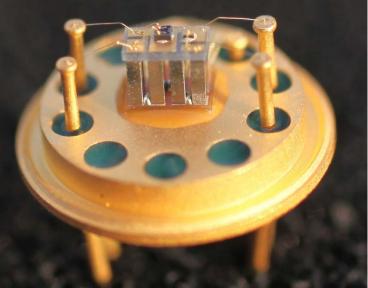


Sensor Assembling



Special handling tools for mounting dices with fragil grids or membrans.

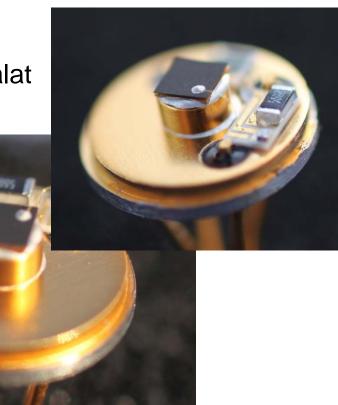
Controlled temperature board.

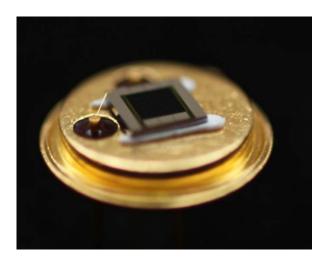




Sensor Assembling

Lithiumtantalat 25 µm thick



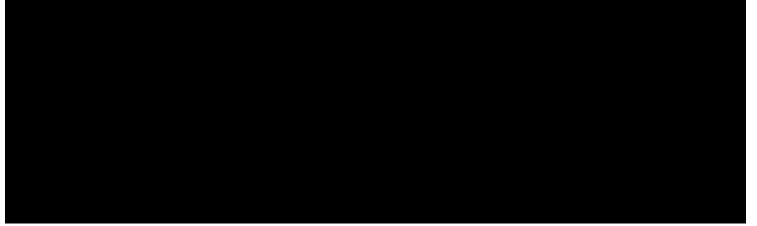


3 µm Membrane



Electronic Assembling

20 GHz Amplifier





Minimum pitch 50 µm



Thank you



Special Techniques

Services:	Feasibility Studies, Design, Prototyping, Manufacturing, Screening, Testing			
Substrate material:	Al ₂ O ₃ , AIN, glass, metals (Mo, steel), polyimide, LCP			
Deposition and Structuring:	4" 6" 24"	Sputtering: Cu, Ni, Au, NiCr, Ti, Cr, Pd, Pt, Sn, Nb, Al Spinning & Laser Direct Imaging (LDI) Electroplating: Cu, Ni, Au, Pt Stripping & Etching		
Laser Processing:		Cutting and Drilling of Polyimide with UV Laser		
Assembly:	Ball-Wedge & Wedge-Wedge bonding, Flip-Chip mounting, Hermetical sealing and Customized packaging			

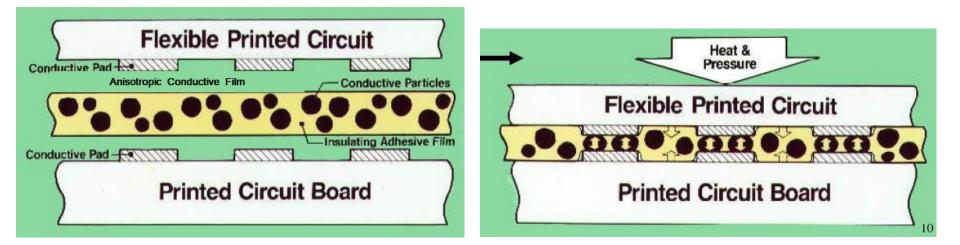


Interconnection by ACF

New tasks Connection of HiCoFlex to PCB's and Hybrids (non-removable)

Methode Heatsealing, by use of Anisotropic Conductive Film (ACF)

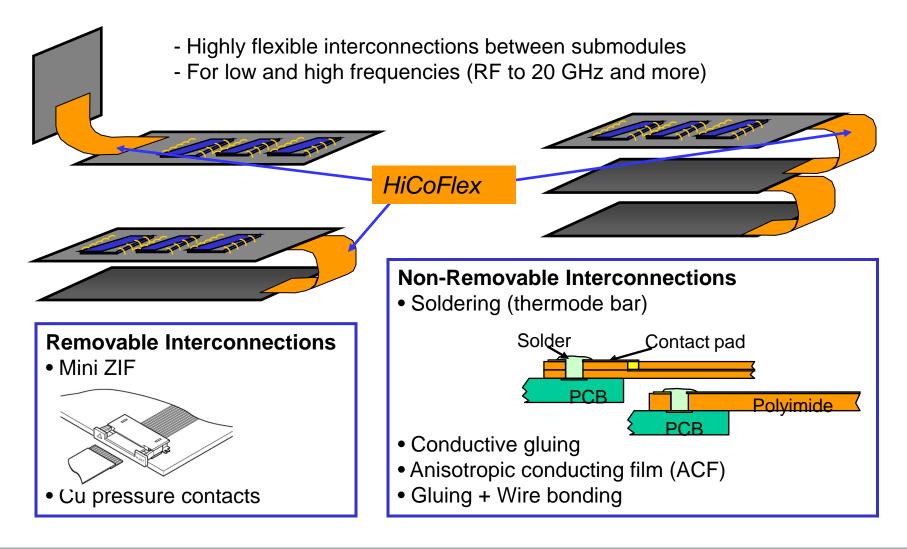
Tests Testsamples \rightarrow Check the possible pitch (range 50 ... 250 μ m),



ACF left before and right after heatsealing



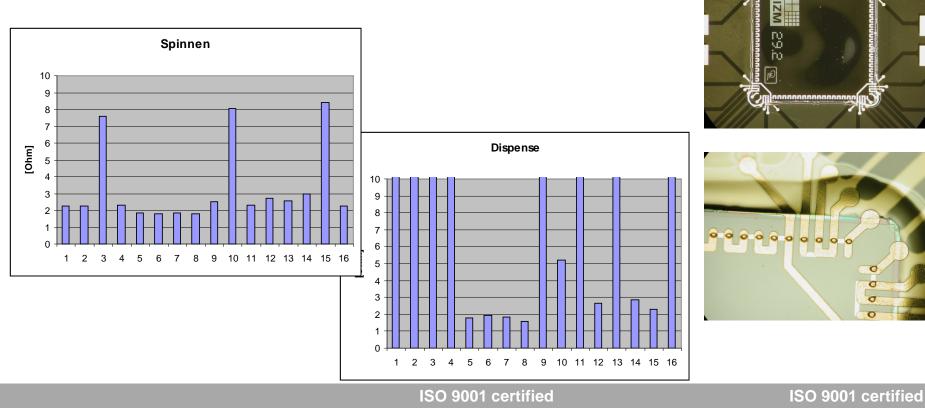
HiCoFlex® Cables and Interconnections





Chip Embedding: Summary of recent work

- Chips embedded with BCB (dispensed or spinned) as glue for the chips.
- Top metallisation (alignment !)
- Measure resistance of daisy chain along one edge of chip (= 36 connections each):
- Typical $\approx 2 \Omega$, some misaligned





The HiCoFlex[®] Process

